

First approach in ink-jet printing

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I. HISTORY OF THE DEVELOPMENT OF THE INK-JET TECHNOLOGY



Three time periods of technological and market development in the ink-jet printing industry

[1] Neil Clymer, Shigeru Asaba, J. Eng. Technol. Manage. 25 (2008) 137-156

3000 patents for 1989-2000 period (Hewlett Packard; Seiko Epson; Canon; Lexmark; Brother; Xerox; Eastman Kodak)

".. ink-jet printing is an incredibly complex technology that appears deceptively simple to the eyes of users

• Five steps in ink-jet printing



II. THE TWO METHODS USED TO PRODUCE DROPLETS

II.1 Continuous Ink jet (CIJ)

Droplets, in the presence of an electrostatic field, acquire a charge





II.2 Drop on demand (DOD)

Droplets are produced by pressure/velocity transients that are caused by volumetric change, which are induced by a piezoelectric material



Conductive and not conductive inks

III. DROP FORMATION IN PRINT HEADS

Fromm obtained an approximate solution to the Navier-Stokes equations to describe droplet formation [4]:

$$Z = \left[\frac{d \rho \gamma}{\eta} \right]^{1/2} = Oh^{-1}$$

Oh⁻¹: Ohnesorge number (dimensionless number)
ρ: density of the fluid
η: viscosity of the fluid
γ: surface tension of the fluid
d: characteristic length (diameter of the printing orifice)

Fromm predicted that drop formation in DOD systems was possible for Z > 2This was latter refined by **Reis** and **Derby** who predicted DOD printing in the range 1 < Z < 10 [3]

[3] Nuno Reis, Chris Ainsley and Brian Derby, J. of App. Phys. 97, 094903 (2005)[4] J.E. Fromm IBM Res. Develop. 28. 3. (1984)

IV. INFLUENCE OF THE CONTACT ANGLE



If gravitational forces are negligible, a liquid droplet deposited on a substrate will equilibrate to a spherical cap with a contact angle Θ

IV.1 YOUG-DUPRE EQUATION

$$\cos \Theta = \frac{\gamma^{\rm SV} - \gamma^{\rm SL}}{\gamma^{\rm LV}}$$

 $\gamma^{\rm LV}$: Interfacial energy between droplet and air $\rm Nm^{-1}$

 γ^{SV} : Interfacial energy between substrate and air Nm⁻¹

 γ^{SL} : Interfacial energy between substrate and droplet Nm⁻¹

[5] J. Stringer, B. Derby ,and al Journ. Of The European Ceramic Society., 29 (2009) 913-918

IV.2 CONSEQUENCES

- Substrates with low surface energy (teflon) are Θ large and low wettability
- Surfactant addition decrease γLV and improve the wettability
- Ex: Triton X100 surfactant, mixed in EG, on Au and SiO₂ surfaces (SiO₂ OTS treated)



Contact angle variation on Au and SiO₂ versus % Triton X100 weight

[6] V. Conedera, F. Mesnilgrente, M. Brunet, N. Fabre ICQNM Cancun Mexique (1-6 February 2009)

IV.3 DROPLET IMPACT AND SPREADING

IV.3.1 Pasandideh-Fard et al (1996) relationship

$$\beta = \frac{d}{d_0} = \frac{We + 12}{3(1 - \cos\theta + 4 (We/Re^{1/2}))}^{1/2}$$

B : spread factor

d : spread diameter

 \mathbf{d}_{\circ} : initial droplet diameter

 Θ :liquid-solid contact angle

Re : Reynolds number = $\rho v d / \mu$

We :Weber number = $\rho v^2 d/\gamma^{lv}$

■ IV.3.2 Other relationship form

$$\beta = \frac{d}{d_0} = \left(\frac{4\sin\theta (1+\cos\theta)}{(1-\cos\theta) (2+\cos\theta)}\right)^{1/3}$$

[7] Taewoong Lim, Sewoon Han et al Intern. Journ. Of Heat Transfert, 52 (2009) 431-441

IV. 4 PREDICTING LINE WIDTH



IV. 5 INSTABILITY OF PRINTED LINES



[9] J.Stringer, B. Derby et al Journ. of the European Ceramic Society , 29 (2009) 913-918

Printed lines can become unstable when the contact angle formed by the liquid with the substrate is larger than the advancing contact angle.



- Other phenomena : at the beginning of the writing
- Material is pumped towards the rear because of the pressure difference which results in bulges being seen





Ex: ZnO deposition: substrate temperature= 110°C; p= 20µm (LAAS-CNRS)



Low particles density at the end of the structure

IV. 6 COFFEE STAINING

For films we want to print uniform features, but after drying, deposition solute is in an external ring.



10% ZnO nanoparticle in ethylene glycol, deposited on silicon (10 drops;. dryed at room temperature

IV.6.1 Deegan theory

The conditions for coffee staining are:

- Volatile and wetting solvent
- Pinned contact line
- Higher evaporation at the edge



The red area represents the volume of liquid removed by evaporation in a single time step Since the contact line is pinned any liquid that evaporates from the edge must be replenished by liquid from the interior.

[11] Deegan and al. Phys. Rev. E., 62 (2000) 756-765

IV.6.2 Solutions (or suggestions) to suppress coffee staining

Reducing edge evaporation is e very good approch! <u>First</u>: by increasing the contact angle



6 droplets of activated carbon deposited on Au and SiO_2 with 30° contact angle



Sessile droplet of activated carbon deposition onto75° angle surface of SiO₂ (OTS treated

[12] V.Conédéra, F. Mesnilgrente, M. Brunet, N. Fabre, ICQNM, 1-6 February 2009 Cancun (Mexique

Second: by addition of a solvent with high boiling point



ZnO profiles : A : 10% ZnO in Ethylene glycol; B: 10% ZnO + 2.5% HBS in Ethylene glycol (LAAS-CNRS)

V.1 ACTIVATED CARBON DEPOSITION FOR SUPERCAPACITORS [12]

Localisation of the printing on the gold electrodes







SEM picture of AC deposited at 140°C onto 10µm wide electrodes



SEM picture of AC deposited on an interdigited structure



detail of the structure

V.2 Carbon nanotubes for RF applications (first result)



CNT deposited onto SiO₂ : chemical confinement by OTS

SEM of NTC (S. Pacchini LAAS-CNRS)

V.3 ZnO nanoparticles for gas detection applications





Gas sensor with (a) square geometry; (b) circular geometry.

Conditions of deposition: 30 drops;50µm diameter of the ink head; substrate temperature 65°C Chemical confinement by OTS Ink composition : 10% ZnO nanoparticles in 2.5% HBS in ethylene glycol (in weight)



SEM gas sensor with circular geometry Conditions of deposition 60 drops; 80 µm diameter of the of the ink head; substrate temperature: 130°C Ink composition: 10% ZnO nanoparticles in ethylene glycol (in weight)

[13] V. Conedera, P. Yoboue, F. Mesnilgrente, P. Menini, N. Fabre, SPIE January 2010 (submit)



VI. THE ALTADROP EQUIPMENT







Piezoresistive actuator : Wave form 12 000 combinations possible!





Ink fabrication : the challenge!!

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- Viscosity : above 40mPa.s, jetting becomes difficult
- The quality of suspensions:
 - Stability with time
 - No agglomeration
 - Chemical compatibility with ink head, pipes and valves...
- Adequation with the substrate....

VII. CONCLUSION

Do you remember:

... ink-jet printing is an incredibly complex technology that appears deceptively simple to the eyes of users!!"

aim :

"it's an exciting subject !!"

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